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Serial No. 09/546,174

Application of: Chih-Chien Liu, Ta-Shan Tseng, W. B. Shieh, J. Y. Wu, Water Lur and

Shih-Wei Sun

Filed: April 11, 2000

Art Unit: 17.11

Examiner: Sergent, Rabon A.

Attorney Docket No. UMC-96-279 CON (JIA-462C1)

HIGH DENSITY PLASMA CHEMICAL VAPOR DEPOSITION PROCESS For:

Confirmation No.: 4793

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Supplemental Amendment.

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#### IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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### SUPPLEMENTAL AMENDMENT AND RESPONSE

MAIL STOP AMENDMENT Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 11 of this paper.